# Interaction of Iron pentacarbonyl with multiply charged ions

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## Electron and ion beam induced processes

• Study of electron and ion beam induced dissociation is important from fundamental and application point of view.

 Electron and ion-beam induced deposition – nanofabrication is one of the important applications.

#### Focused beam nanofabrication





**FEBID** = focused electron-beam induced deposition (traditional) **FIBID** = focused ion-beam induced deposition (emerging field)



#### Pyramid connecting four electrode



#### Clamp to fix nanowires



Reviews: Utke et al., J. Vac. Sci. Technol. 2008, Thorman et al., Beilstein J. Nanotechnol. 2015

## Role of secondary low-energy electrons



#### Precursor Molecules



## Electron – induced chemistry in Fe(CO)<sub>5</sub> (gas phase)

• Electron impact ionization – very fragmentative



Dissociative electron attachment

- Very low electron energies (< 1 eV)</li>
- Cleaves only one metal-ligand bond
- Very high cross sections



Co(CO)<sub>3</sub>NO S. Engmann et al., ACIE 2011



Pt(PF<sub>3</sub>)<sub>4</sub> O. May et al., PCCP 2012



## Back-draws of FEBID

#### Problems of FEBID:

- Spatial resolution much worse than it could be Deposits – few beam diameters wide – low energy secondary electrons
- Purity of the deposits Metal content typically 15 to 75 % (incomplete dissociation of precursor)

#### Alternative – use of focused ion beam

30 keV Gallium Ion Beam 1 keV electron Beam 30 keV Helium Ion Beam

Alkemade and Miro, Appl. Phys. A (2014)

- Focused ion beam induced deposition is becoming an important tool.
- Spread of secondary electrons interacting with precursor molecule is low.

#### **COLIMACON TOF mass spectrometer**



- detection of high mass fragments (clusters)
- coincident detection of fragments
- metastable ion detection

ARIBE low energy ion beamline at GANIL facility in CAEN, Fr

#### Current study



#### Multiple charge: 16 keV <sup>4</sup>He<sup>2+</sup>, 40 keV <sup>20</sup>Ne<sup>4+</sup> 21 keV <sup>40</sup>Ar<sup>3+</sup> 12 keV <sup>84</sup>Kr<sup>3+</sup> 255 keV <sup>84</sup>Kr<sup>17+</sup>

Fragmentation can happen via different processes – depending on ion velocity, mass ratio and charge state

- Ion can interact with electronic cloud of the molecule
  - Electron excitation and electron capture
- Ion can interact with molecular nuclei
  - Vibrational excitation Sufficient for emission of a nucleus

#### Interaction with singly charged ions





NFor With precipertilien eterchrololi 6 excitation viend and ethomeraphigener domerigy antaprofeess both electrobicaptome and gyuis 24r5 exettation plays a role

Ar<sup>+</sup> is dominated by nuclear excitation

## Interaction with multiply charged ions





Electron capture at larger inter-nuclear distance – low energy transfer – more intact molecule

#### Fragmentation efficiency



Number of Fe atoms per CO group

#### Maximum kinetic energy of the fragment ions



## Conclusion

- The kinetic energy of fragments almost independent of the ion energy rather depends largely on the precursor molecule – Proper selection of precursor molecule is important
- Fe(CO)<sub>5</sub> is a potential precursor molecule to have less spatial spread due to low fragment kinetic energy.
- Singly charged <sup>20</sup>Ne<sup>+</sup> ion beam is best projectile to produce purest metal deposition.



#### Decomposition of Iron Pentacarbonyl Induced by Singly and Multiply Charged Ions and Implications for Focused Ion Beam-Induced Deposition

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#### Acknowledgement







![](_page_15_Picture_4.jpeg)

![](_page_15_Picture_5.jpeg)

## Thank You

#### Metastable ion decay

![](_page_17_Figure_1.jpeg)